	Application No.	Applicant(s)
Notice of Allowability	10/771,404 Examiner	MIYAIRI ET AL.
·	William M. Brewster	2823
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>7 July 2005</u> .		
2. The allowed claim(s) is/are 1-18.		
3. The drawings filed on <u>05 February 2004</u> are accepted by the Examiner.		
4.		
<ul> <li>Attachment(s)</li> <li>1. ☑ Notice of References Cited (PTO-892)</li> <li>2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0: Paper No./Mail Date 020504</li> <li>4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ul>	6. ☐ Interview Summary Paper No./Mail Dat 8), 7. ⊠ Examiner's Amendm	e

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## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

## a) In the Title

After "same", insert --Including Adding Metallic Element to the Amorphous Semiconductor Film and Introducing Oxygen after Crystallization"

## **Reasons for Allowances**

The following is an examiner's statement of reasons for allowance: Moon (274) teaches implanting oxygen for crystallization. Nakajima (282) teaches the oxygen concentration only as an incidental, but not purposely introduced. Neither has the features in claim 2, lines 8-14, "a fourth step of introducing oxygen into the semiconductor film having a crystalline structure to make the oxygen concentration within the film from 5x10<sup>18</sup>/cm³ to 1 x10<sup>21</sup>/cm³;

a fifth step of removing an oxide film on the surface of the semiconductor film having a crystalline structure, and

a sixth step of irradiating laser light under an inert gas atmosphere or in a vacuum to level the surface of the semiconductor film having a crystalline structure."

The prior art of record fails to teach, in combination, the process features.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William M. Brewster whose telephone number is 571-272-1854. The examiner can normally be reached on Full Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

18 August 2005

William M. Brownton

WB